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| Session Title: | [WeF3] Nano Thin Film Deposition V |
| Session Date: | November 13 (Wed.), 2024 |
| Session Time: | 16:05-17:45 |
| Session Room: | Room F (Ballroom, 5F, Grand Josun Busan) |
| Session Chair: | Prof. Taewook Nam (Sejong Univ., Korea) |

[WeF3-1] [Invited] 16:05-16:35

Interfacial Engineering for Ferroelectric Memories with Improved Performance

Mihaela Ioana Popovici (imec, Belgium)

[WeF3-2] [Invited] 16:35-17:00

Correlation between Device Physics and Material Chemistry in (Hf,Zr)O₂-Based Ferroelectric Memories

Min Hyuk Park (Seoul Nat'l Univ., Korea)

[WeF3-3] [Invited] 17:00-17:25

Synthesis of Perovskite SrTiO₃ Thin Films by Atomic Layer Deposition for MIM Capacitors

Woongkyu Lee (Soongsil Univ., Korea)

[WeF3-4] 17:25-17:45

Achieving Superior ALD Metal Oxide Films with Organic Molecule Inhibitors

Seung Hyun Lee, Deok Hyun Kim, Kok Chew Tan, Jung Hun Lim, Young-Soo Park, and Jaesun Jung (Soulbrain Co., Ltd., Korea)